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Y. Aoki, S. Hirata, H. Habazaki P41

Facile Electrochemical Fabrication of Large-Area ZnO Inverse Opals with Reduced Defects

Y.-J. Huang, C.-H. Liao, B.-H. Huang, W.-Y. Chen, P.-W. Wu P45

Miscellaneous

Erratum: Soft X-Ray Spectroscopic Study of Dense Strontium-Doped Lanthanum Manganite Cathodes for Solid Oxide Fuel Cell Applications [J. Electrochem. Soc., 158, B99 (2011)]

L. F. J. Piper, A. R. H. Preston, S.-W. Cho, A. DeMasi, B. Chen, J. Laverock, K. E. Smith, L. J. Miara, J. N. Davis, S. N. Basu, U. Pal, S. Gopalan, L. Saraf, T. Kaspar, A. Y. Matsuura, P.-A. Glans, J.-H. Guo S9

Publisher's Note: Reduction of an Electrochemistry-Based Li-Ion Battery Model via Quasi-Linearization and Padé Approximation [J. Electrochem. Soc., 158, A93 (2011)]

J. C. Forman, S. Bashash, J. L. Stein, H. K. Fathy S10

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